

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/023,825 Confirmation No. 8239
Applicant : Jorge A. Kittl et al.
Filed : 12/19/2001
TC/A.U. : 2829
Examiner : Russell M. Kobert

Docket No. : TI-23892
Customer No. : 23494

Title : METHOD TO IMPROVE SILICIDE FORMATION ON
POLYSILICON

REQUEST FOR EXTENSION OF TIME

Commissioner of Patents
PO Box 1450
Alexandria, VA 22313-1450

Dear Sir:

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the following papers are being transmitted by facsimile to the U.S. Patent and Trademark Office at 703-872-9306 on the date shown below:


Jacqueline J. Garner, Reg. No. 36,144

January 20, 2004
Date

Pursuant to 37 CFR 1.136(a), Applicant(s) respectfully petitions the Commissioner for an extension of the shortened statutory period for response in the above-identified Application.

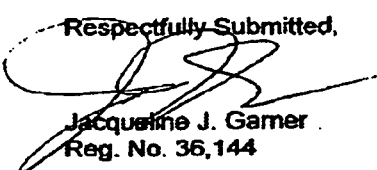
The fee for this extension is indicated below:

- ☒ One Month (\$110)
☐ Two Months (\$420)
☐ Three Months (\$950)
☐ Four Months (\$1,480)

Please charge the fee to deposit account no. 20-0688. Any further necessary extension of time is hereby requested. Charge any and all fees to deposit account no. 20-0688. An original and two copies of this sheet are enclosed.

Texas Instruments Incorporated
PO Box 655474, M/S 3999
Dallas, TX 75265
(214) 532-9348
Fax: (972) 917-4418

Respectfully Submitted,


Jacqueline J. Garner
Reg. No. 36,144